



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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TECHNOLOGY CENTER 1700

In re PATENT APPLICATION of

SUZUKI, et al.

Group Art Unit: 1752

Appln. No.: 09/712,182

Examiner: Clarke, Y.M.

Filed: November 15, 2000

Title: METHOD OF PROCESSING LIGHT-SENSITIVE MATERIAL

* * * * *

June 24, 2002

AMENDMENT

Hon. Commissioner of Patents
and Trademarks
Washington, D.C. 20231

Sir:

In response to the Office Action dated March 27, 2002, please amend the
subject application as follows:

IN THE SPECIFICATION:

(See the attached Appendix for the changes made to effect the below
amendments):

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Paragraph starting at page 36, line 28 of specification

In the same manner as in Example 4, peeling sheets F to H having the following
liquid-absorption characteristics were prepared except for changing the coated
amount of the silica layer in the peeling sheet A. In the peeling sheet F, liquid-
absorption amounts (ml) 0.1 second/0.2 second after contacting with the
developing solution per 1 m² were 22 ml/28 ml, respectively. Similarly, they were

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